

Multi-Layer Solid State Keyboard

CROSS-REFERENCE TO RELATED APPLICATION

This application claims priority from United States Provisional Patent Application Serial No. 60/464,483, filed on April 22, 2003, the disclosure of which is incorporated herein by reference.

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BACKGROUND OF THE INVENTION

1. The Technical Field

The present invention is directed generally to a solid state keyboard. More particularly, the present invention is directed to a solid state keyboard integrating decorative and functional layers.

2. The Related Art

Keypad input systems typically are assemblies of several components. For example, a typical keypad includes a glass, plastic, or flexible film face plate or front panel that acts as a user interface. This face plate might include graphics that describe the keypad's functionality and/or other indicia, such as a logo, for purely decorative purposes. Such a keypad further includes another panel that includes, for example, field effect sensor electrodes and control circuitry. These two panels typically are manufactured as separate subassemblies that are later joined to form a finished keypad.

Some keypads use reconfigurable keys in connection with a reconfigurable display. One example of such a system includes a dot matrix display that provides prompts to a user and solicits input from the user via one or more mechanical switches, for example, membrane switches, situated about the display and proximate the various prompts. Such a

system may guide a user through various menu levels, wherein the displayed prompts corresponding to a particular switch vary from level to level and the function of the switch changes correspondingly. One drawback with such a system is that it is not always clear to the user which switch, if any, is associated with a particular display prompt. Another is that 5 membrane switches, commonly used in such applications, are prone to premature failure when used in high traffic applications.

Computer touch screen technology, as sometimes used in connection with cash register input pads and consumer product information kiosks, offers a better solution, but involves greater cost and complexity. Indeed, such systems typically require PC-based or 10 proprietary decoding hardware. Further, the hardware requirements for such systems prohibit their use in applications where little space is available.

SUMMARY OF THE INVENTION

The present invention is an integrated solid state keypad having multiple 15 layers, including decorative layers and functional layers. The keypad includes one or more keys which preferably are embodied as field effect sensors. In certain embodiments, one or more of the keys are reconfigurable keys that can be used in connection with a reconfigurable display. Preferably, the reconfigurable keys are embodied as field effect sensors having transparent electrode structure.

BRIEF DESCRIPTION OF THE DRAWINGS

FIG. 1 is a front elevation view of a keypad according to the present invention;
FIG. 2 is a side elevation view of a keypad according to the present invention;
FIG. 3 is a rear elevation view of a keypad according to the present invention,

illuminating a transparent conductive layer on a substrate;

FIG. 4 is a rear elevation view of a keypad according to the present invention, illustrating a conventional conductive layer on a substrate;

FIG. 5 is a rear elevation view of a keypad according to the present invention, 5 illustrating a solder mask or dielectric layer on a substrate;

FIG. 6 is a rear elevation view of a keypad according to the present invention, illustrating an additional dielectric layer on a substrate; and

FIG. 7 is a rear elevation view of a keypad according to the present invention, illustrating crossovers for connecting a first conductive layer to a second conductive layer.

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DETAILED DESCRIPTION OF THE ILLUSTRATED EMBODIMENT

FIG. 1 illustrates the front, or user interface, side 12 of a keypad 10 according to a preferred embodiment of the present invention. Keypad 10 includes a viewing window 14, three reconfigurable keys 16, and twenty non-reconfigurable keys 18 disposed on a substrate 20. Keys 16,18 correspond to field effect sensors, capacitive sensors, or other sensors disposed on the rear side of keypad 10, as will be discussed further below. The precise combination of features illustrated in FIG. 1 is not essential to the invention and is shown for illustration only. Indeed, other embodiments of the invention could have more or fewer viewing windows, reconfigurable keys, or non-reconfigurable keys. Further, some 15 embodiments might lack one or more of these features entirely.

FIG. 2 is a side elevation view showing the various layers comprising keypad 10. FIG. 2 illustrates a preferred arrangement of the various layers. In other embodiments, the various layers can be arranged in other ways and/or sequences, as would be understood by one skilled in the art. Substrate 20, which forms the core of keypad 10, can be any rigid or

flexible material suitable for receiving decorative materials and conductive thin films. For example, substrate 20 can be a piece of glass or plastic or a flexible carrier made of polyester.

Layers 22,24,26,28 are layers of decorative material. These decorative material layers can provide functional information, such as graphics depicting the function of a particular key, or purely decorative graphics, for example, a decorative pattern or logo, are applied to one or both sides of substrate 20. FIG. 2 illustrates one decorative layer 22 on the user interface side of substrate 20 and three decorative layers 24,26,28 on the rear side of substrate 20. In other embodiments more or fewer decorative layers can be used on each side of substrate 20.

In preferred embodiments, decorative layers 22,24,26,28 comprise organic decorative materials, for example, screen printed inks, epoxies, and ultraviolet curable materials. Other decorative materials, including inorganic materials, can be used, as well. The various decorative layers can be substantially opaque, translucent, or substantially transparent. In embodiments having viewing window 14, any decoration located within the area of viewing window 14 preferably is substantially transparent so that a user can view a display (not shown) that might be mounted behind viewing window 14 or so that backlighting can be penetrate viewing window 14. Further, decoration located within the area of viewing window 14 can be selected to have certain optical properties so that such decoration acts as an optical filter.

Layer 30 is an optional, substantially transparent layer of conductive material. Referring to FIG. 3, transparent conductive layer 30, when used, preferably is configured as transparent electrodes and electrical circuit traces 32. Transparent electrodes and traces 32 can be located anywhere on substrate 28. For example, transparent electrodes and traces 32 can be located on decorated portions of substrate 18, between substrate 18 and the decoration,

such the decoration is viewable through transparent electrodes and traces 32. In applications using backlighting, transparent electrodes and traces 32 can be used in backlit portions to allow the backlighting to reach the user without occlusion as would be the case if electrodes and traces 32 were made of a conventional, opaque material. Referring to FIG. 1, it can be 5 particularly desirable to use transparent electrodes and traces 32 to embody reconfigurable keys 16 or other keys located in the area corresponding to viewing window 14 so that the output of a display (not shown) mounted behind viewing window 14 is visible to the user.

As discussed further below, electrical circuit components can be coupled to transparent electrodes and traces 32 to form field effect sensors, capacitive sensors, or other 10 sensors. Transparent conductive layer 30 can be applied in various ways. For example, transparent conductive layer 30 can be deposited in a desired pattern using screen printing or micro-deposition techniques. Alternatively, transparent conductive layer 30 can be plated or applied as a thin film utilizing, for example, sputtering or thermal evaporation techniques, and then patterned and etched to yield transparent electrodes and traces 32. Other suitable 15 techniques, for example, spin coating, also can be used to apply transparent conductive layer 30, as would be known to one skilled in the art.

FIG. 2 illustrates transparent conductive layer 30 disposed onto decorative layer 28, which ultimately is disposed on substrate 20. Alternatively, transparent conductive layer 30 can be disposed directly onto substrate 20. In such an embodiment, a decorative 20 layer (not shown) optionally can be disposed on transparent conductive layer 30. In embodiments where transparent conductive electrodes and traces 32 are disposed above or below one or more decorative layers, at least the portions of such decorative layers that are coextensive with transparent conductive layer 30 preferably are substantially transparent and can comprise material having optical filtering properties. Preferred materials for transparent

conductive layer 30 include, for example, inorganic materials, such as indium tin oxide, or organic materials, such as Baytron PEDOT.

Layer 40 is a layer of conventional conductive material disposed on transparent conductive layer 30. Preferably, conventional conductive material layer 40 is 5 made of a polymer thick film silver or copper epoxy, such as that supplied by Acheson Colloids Company of Port Huron, Michigan. In other embodiments, this layer can be made of plated copper or other conductive material. Referring to FIG. 4, conventional conductive layer material 40 preferably is arranged in the form of field effect sensor electrodes 42, electrical circuit traces 44, and bonding pads 46. As discussed further below, electrical circuit 10 components, for example, integrated circuits, transistors, and resistors (not shown), can be coupled to electrodes 42 and traces 44 via bonding pads 46 to form field effect sensors, capacitive sensors, or other sensors. Preferably, such components are connected to bonding pads using conventional soldering techniques. Alternatively, such connections can be made using conductive adhesives, anisotropic adhesives, or other suitable means, as would be 15 known to one skilled in the art. Conventional conductive material layer 40 can be applied using any suitable technique as would be known to one skilled in the art, for example, any of the techniques discussed above in connection with the application of optional transparent conductive layer 30.

Referring to FIGS. 2 and 5, layer 50 is a solder mask/dielectric layer disposed 20 on conventional conductive layer 40 and/or transparent conductive layer 30. Layer 50 provides a solder mask, leaving exposed the portions of conductive layer 40 to which electrical circuit components are to be bonded. For example, solder mask 50 can be designed to leave exposed bonding pads 46 to facilitate bonding of integrated circuits and other electrical components to bonding pads 46. In this manner, field effect sensors or other

sensors corresponding to keys 16,18 can be constructed *in situ* on substrate 20. Although it generally is not preferred to couple such circuit components directly to transparent conductive layer 30, solder mask layer 50 can be designed to leave exposed portions of transparent conductive layer, as necessary, to facilitate such bonding.

5 Layer 50 also can provide electrical insulation between conventional conductive material layer 40 and transparent conductive layer 30 and further layers of keypad 10. For example, a particular circuit design might require the use of crossovers 70, as illustrated in FIG. 7 and as would be known to one skilled in the art. If layer 50 is selected to have suitable dielectric properties, such crossovers can be applied over layer 50 and bonded at 10 the appropriate points to conventional conductive layer 40 (and/or transparent conductive layer 30, as necessary). In such embodiments, layer 50 insulates crossovers 70 from portions of conventional conductive layer 40 (and/or transparent conductive layer 30, as necessary) which crossovers 70 otherwise would contact, causing the potential for short circuits.

Layer 60 is an optional dielectric layer that can be used in embodiments 15 involving crossovers 70. As discussed above in connection with layer 50, optional dielectric layer 60 provides electrical insulation between electrical crossovers and conductive portions of keypad 10 to be bridged by such crossovers.

A reconfigurable display (not shown) can be disposed on the rear side of keypad 10 adjacent the area corresponding to viewing window 14, allowing a user to view the 20 display through viewing window 14. Such embodiments preferably include reconfigurable keys 14 comprising field effect sensors or other sensors having transparent electrode structure with in the area corresponding to viewing window 14. The functions of such sensors preferably would be reconfigurable, as would be known to one skilled in the art, to conform to the subject matter set forth in the display in the area corresponding to such sensors.

While specific embodiments of the present invention have been shown and described above, it will be obvious to those skilled in the art that numerous modifications made be made without departing from the spirit of the invention, the scope of which is defined by the claims below.